

# COMPOL

Exotic  
Material Polish



该照片是示意图。This photograph is an image.

## COMPOL

COMPOL 是专为 LiTaO<sub>3</sub>、LiNbO<sub>3</sub>、蓝宝石等电子材料基盘、金属材料及陶瓷的抛光而开发的高纯度胶态二氧化硅浆料。颗粒的均匀性、分散性出色,能够高效地得到无损伤的研磨面。

## COMPOL

COMPOL is a colloidal silica slurry developed especially for polishing metals, ceramics and electronic substrates such as LiTaO<sub>3</sub>, LiNbO<sub>3</sub> and sapphire. With excellent particle uniformity and dispersal, it delivers high-removal rate, damage free polishing. Even when used at high dilutions, COMPOL delivers excellent processing efficiency and long slurry life.

### COMPOL的代表物性 Typical Physical Properties of COMPOL

产品名 Type	20	50	80	120
项目 Item				
SiO <sub>2</sub> 含量 Content of SiO <sub>2</sub> (%)	40	40	40	40
PH	9.2	10.2	10.2	9.2
比重 Specific gravity	1.30	1.30	1.30	1.30
平均粒径 Average particle size (nm)	15.0	40.0	72.0	82.5
标准净重 Standard Net weight	20kg	20kg	20kg, 260kg	20kg

用途: 蓝宝石、CaF<sub>2</sub>、BGO、LiTaO<sub>3</sub>、LiNbO<sub>3</sub>等氧化物晶体  
applications:sapphire, CaF<sub>2</sub>, BGO, LiTaO<sub>3</sub>, LiNbO<sub>3</sub> and other oxide crystals

产品名 Type	EX-3	403
项目 Item		
SiO <sub>2</sub> 含量 Content of SiO <sub>2</sub> (%)	50	46
PH	9.5	9.3
比重 Specific gravity	1.385	1.340
平均粒径 Average particle size (nm)	32.5	39.0
标准净重 Standard Net weight	20kg	20kg

用途: 蓝宝石、CaF<sub>2</sub>、BGO、LiTaO<sub>3</sub>、LiNbO<sub>3</sub>等氧化物晶体  
applications:sapphire, CaF<sub>2</sub>, BGO, LiTaO<sub>3</sub>, LiNbO<sub>3</sub> and other oxide crystals